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# Nickel Supported on Mesoporous Zirconium Oxide by Atomic Layer Deposition: Initial Fixed-Bed Reactor Study

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## Abstract

Atomic layer deposition (ALD) is gaining attention as a catalyst preparation method able to produce metal (oxide, sulphide, etc.) nanoparticles of uniform size down to single atoms. This work reports our initial experiments to support nickel on mesoporous zirconia. Nickel (2,2,6,6-tetramethyl-3,5-heptanedionate)<sub>2</sub> [Ni(thd)<sub>2</sub>] was reacted in a fixed-bed ALD reactor with zirconia, characterised with BET surface area of 72 m<sup>2</sup>/g and mean pore size of 14 nm. According to X-ray fluorescence measurements, the average nickel loading on the top part of the support bed was on the order of 1 wt%, corresponding to circa one nickel atom per square nanometre. Cross-sectional scanning electron microscopy combined with energy-dispersive spectroscopy confirmed that in the top part of the fixed support bed, nickel was distributed throughout the zirconia particles. X-ray photoelectron spectroscopy indicated the nickel oxidation state to be two. Organic thd ligands remained complete on the surface after the Ni(thd)<sub>2</sub> reaction with zirconia, as followed with diffuse reflectance infrared Fourier transform spectroscopy. The ligands could be fully removed by oxidation at 400 °C. These initial results indicate that nickel catalysts on zirconia can likely be made by ALD. Before catalytic testing, in addition to increasing the nickel loading by repeated ALD cycles, optimization of the process parameters is required to ensure uniform distribution of nickel throughout the support bed and within the zirconia particles.

**Keywords** Atomic layer deposition · Zirconia · Nickel · Catalyst · Ligand removal · Particles

## 1 Introduction

Atomic layer deposition (ALD) is a thin film growth method that allows the preparation of uniform inorganic material layers on arbitrarily complex three-dimensional structures. The three-dimensional uniformity, also termed “conformality,” is a consequence of the systematic use of repeated, self-terminating (saturating, irreversible), separated gas–solid

reactions of at least two compatible compounds [1–6]. While the principles of ALD were formulated already in the 1960s and 1970s, independently twice [7–14], it was in the 1990s that ALD was promoted as a tool for nanotechnology [15] and during the 2000s that ALD has enabled the continuation of Moore’s law of transistor miniaturisation [16]. By the end of 2010, over 700 two-reactant ALD processes had been developed [17]. The Finnish inventor of ALD, Dr. Tuomo Suntola, received the prestigious Millennium Technology Prize in 2018 [18].

ALD can coat conformally porous high-surface-area catalyst supports by catalytically active materials. The first reports of the use of ALD for preparing supported heterogeneous catalysts are from the Soviet Union in the early 1970s, typically reported under the name “molecular layering” [12, 19–24]. In 1990s, there was a strong industry-driven effort for ALD for catalysis in Finland; the technique was then called “atomic layer epitaxy” [11, 25–32]. Interest in ALD for the preparation of supported heterogeneous catalysts has again been increasing during the past decade [33–39]. The

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current interest in ALD is based for example in the ability of ALD to prepare (close to) monodisperse metal particles; to make overcoatings to temper the activity of highly active but non-selective sites; and to prepare single-atom catalysts. The solvent-free nature of ALD is generally regarded an environmental advantage, and scaling up the catalyst preparation should be feasible.

Various reactor designs can be used for coating particles by ALD. Many of the early ALD catalyst works in the Soviet Union and Finland employed fixed-bed reactors [12, 24, 31]; fixed-bed reactors have recently re-gained interest [37]. Also fluidised bed [40–42] and rotary bed [43, 44] reactors have been used. Thanks to the advances on ALD in the field of microelectronics, many groups have recently used a reactor set-up where a tray of powder is placed in a reactor optimised for thin film growth [34]. Whatever the reactor type, the strength of ALD is best employed when the whole particle bed is coated with a uniform, conformal material layer. Attainment of saturation is not self-evident [39, 45]; conformality in extreme aspect ratios needs process tuning and should be verified.

Nickel is a well known hydrogenation catalyst. Supported nickel catalysts were among the first ALD catalysts studied in Finland in the 1990s, with focus on toluene hydrogenation [28, 29]. More recently, nickel catalysts have received attention for example in biomass gasification, not only because of their low price compared to noble metals, but also because they are highly active in tar cracking and reforming [46]. Nickel can be used for CO<sub>2</sub> hydrogenation on silica-supported catalysts [47] and aqueous phase reforming of alcohols on zirconia containing supports [48]. In general, ZrO<sub>2</sub> is considered as an attractive catalyst support due to its high thermal stability and amphoteric nature [49].

This work reports an initial study to prepare nickel catalysts on a mesoporous zirconia support by ALD cycles. We used Ni(thd)<sub>2</sub> (thd = 2,2,6,6-tetramethyl-3,5-heptanedionate), a traditional ALD reactant [50–53], as the nickel source; and air as the oxygen source. To our best knowledge, this work is the first to report the ALD modification of mesoporous zirconia with nickel.

## 2 Experimental

### 2.1 Materials

The precursor Ni-bis-2,2,6,6-tetramethyl-heptane-3,5-dionate (Ni(thd)<sub>2</sub>) was synthesised from nickel(II) acetate tetrahydrate (J.T. Baker Chemical, > 98%) and 2,2,6,6-Tetramethyl-3,5-heptanedione (Tokio Chemical Industrie Co., > 97%) according to literature methods [53, 54] and purified by sublimation under vacuum before

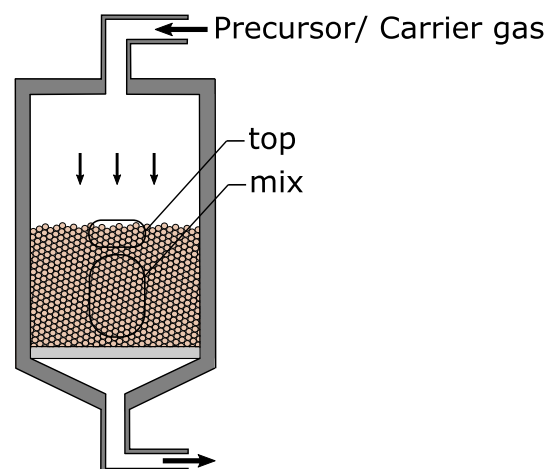
use. Mesoporous zirconium oxide (Saint-Gobain Norpro, monoclinic < 0.2 wt% SiO<sub>2</sub>) was crushed and sieved to 250–450 µm particles, calcined in synthetic air (purity 5.0, Oy AGA Ab) at 600 °C for 10 h and stored in an desiccator.

### 2.2 N<sub>2</sub> Physisorption

Nitrogen physisorption isotherms were measured at isothermal conditions in liquid nitrogen (77 K) using a Thermo Fisher Surfer equipment. The fresh, 600 °C heat-treated zirconia support (0.24 g) was weighted in a quartz tube and evacuated at 350 °C for 3 h (heating ramp 5 °C/min) prior to the measurement. Specific surface area was calculated from the adsorption isotherm according to the Brunauer–Emmett–Teller (BET) theory using the relative pressure  $p/p^0$  range of 0.2–0.4 [55]. Pore size distribution, mean pore diameter and total pore volume were calculated using the Barrett–Joyner–Halenda (BJH) method [56].

### 2.3 ALD Procedure

The experiments were carried out using an F-120 flow-type ALD reactor, modified to accommodate a porous high-surface-area materials in a fixed bed (ASM Microchemistry Ltd., Finland). The reactor and procedure were similar as described e.g. by Haukka et al. [31]. Schematic illustration of the fixed particle bed is shown in Fig. 1. The reaction chamber for powders (diameter 2 cm) was used with the associated filter to hold up to ca. 5 g of support. The particle bed height was over one centimetre (accurate height not measured). The Ni(thd)<sub>2</sub> reactant was placed in an open glass boat within the reactor and sublimated at 140 °C, operated under a moderate vacuum of 0.6–4 mbar (pressure measured after the support bed). Nitrogen (> 99.99999%, generated



**Fig. 1** A schematic illustration of the fixed-bed F-120 ALD reaction chamber. Samples were separately taken from the top of the particle bed and mixing the rest of the material as one sample

with a Parker HPN2-5000 from air, with less than 10 ppm of oxygen) was used as a carrier and purging gas, with constant flow rate of 400 sccm. The support was stabilised at 400 °C for 3 h in a stream of nitrogen. After this, the temperature was stabilised to the desired reaction temperature (200 °C) and the reactant vapour was led downwards through the fixed support bed for 3 h. After the reaction, the sample was purged with nitrogen at the reaction temperature for 2 h. At the end of the run, the reactor was cooled in nitrogen flow close to room temperature before unloading. Samples were taken from the top part of the support bed and mixing the rest of the material as one sample. The samples were stored in a desiccator.

## 2.4 X-ray Fluorescence

The chemical composition and nickel loading of the prepared materials were measured semiquantitatively by X-ray fluorescence (XRF) using a PANalytical AxiosMax Wavelength Dispersive X-ray Fluorescence Spectrometer (WD-XRF). The device was equipped with a scintillation detector and a rhodium tube, which operated at 60 kV with a current of 50 mA. The samples (100–500 mg) in powder form were placed on a supporting thin film using XRF sample cup (32 mm width).

## 2.5 X-ray Photoelectron Spectroscopy

The X-ray photoelectron spectroscopy (XPS) measurements were made using Kratos Axis Ultra system, equipped with a monochromatic AlK $\alpha$  X-ray source. All measurements were performed with 0.3 mm  $\times$  0.7 mm analysis area and the charge neutraliser on. A wide scan was performed with 80 eV pass energy and 1 eV energy step. High resolution scans were performed with 20 eV pass energy, 0.1 eV steps size for 5 min for the C 1s, Zr 3d and O 1s and for 20 min for Ni 2p. The energy calibration was made using the adventitious carbon C1s component at 284.8 eV. All deconvolutions were made with CasaXPS using GL(30) peaks (product of 30% Lorentzian and 70% Gaussian). Information depth in XPS is roughly ten atomic layers.

## 2.6 Scanning Electron Microscopy and Energy-Dispersive X-ray Spectrometry

Scanning electron microscopy (SEM) and energy-dispersive X-ray spectrometry (EDS) examination was carried out using Tescan Mira3 scanning electron microscope fitted with a Thermo Scientific energy-dispersive X-ray spectrometer. The EDS system was equipped with silicon drift detector (SDD). In sample preparation, mesoporous Ni(thd)<sub>2</sub>-modified zirconia particles were mounted in epoxy resin utilizing vacuum impregnation. The cured mounts were ground and polished

to expose cross-sections of the particles at the face of specimen. Subsequently, specimens were coated with carbon to prevent charging under the electron beam. In the SEM and EDS examination, electron accelerating voltage of 15 keV was used. First, qualitative elemental analysis was performed to identify elements present in the specimen. Secondly, EDS line scans were performed across a selected Ni(thd)<sub>2</sub>-modified zirconia particle. The length of the line was 600  $\mu$ m including 100 measurement points. Integration of 40 scans was utilised to improve precision of the measurement. Estimated detection limit of EDS is 0.1–0.3 wt%.

## 2.7 Thermogravimetric Analysis (TGA)

The thermal properties of the nickel-modified zirconia were studied with ambient pressure thermogravimetric analysis (TGA) with the TGA Q500 (TA Instruments, USA). Heating rate of 10 °C/min and temperature range of 30–600 °C were used. To reduce the amount of moisture, the sample was pre-heated ex situ for 2 h in air at 200 °C before the TGA analysis, and then quickly transferred into the TGA equipment. The TGA analysis was started with heating in nitrogen up to 200 °C and holding for 1 h, after which the gas was changed to oxygen and heating was continued until 600 °C.

## 2.8 Diffuse Reflectance Infrared Fourier Transform (DRIFT) Spectroscopy

Diffuse reflectance infrared Fourier transform (DRIFT) spectroscopy measurements were made to observe the vanishing of ligands during oxidation at elevated temperatures. Measurements were made with a Nicolet Nexus FTIR spectrometer using a Spectra-Tech in situ high temperature/high pressure chamber equipped with deuterated triglycine sulphate (DTGS) detector. The total gas flow was kept at 50 sccm throughout the measurement. The sample-holder-cup was filled with 2/3 pure zirconia (approx. 12 mg) at the bottom and 1/3 Ni(thd)<sub>2</sub>-modified zirconia (approx. 5 mg) at the top. The applied background was the spectra of an aluminium mirror (4 cm<sup>-1</sup> resolution, 200 scans) in the in situ cell under nitrogen flow.

First, the sample was pre-heated in the in situ cell in nitrogen (N<sub>2</sub> 99.999%, Oy AGA Ab) at 200 °C for 3 h, followed by cooling down to 30 °C. This was done to reduce moisture, which had been transferred within the sample to the in situ cell through ambient air. Next, the oxidation of the surface species was studied by feeding 10% O<sub>2</sub>/N<sub>2</sub> (synthetic air 99.99%, Oy AGA Ab) to the chamber at 30 °C followed by increasing the temperature stepwise (steps of 25 °C) to 500 °C. During the stepwise heating of the sample, spectra (4 cm<sup>-1</sup> resolution, wavenumber range 4000–1000 cm<sup>-1</sup>, 100 scans) were recorded every 25 °C, i.e., approximately every 4 min.

### 3 Results and Discussion

#### 3.1 Porosity Characterization of the Support

The porosity of the zirconia support heat-treated at 600 °C for 10 h in synthetic air was investigated through nitrogen physisorption. The N<sub>2</sub> adsorption and desorption isotherms, shown in Fig. 2a, present hysteresis typical for a mesoporous structure [57]. The BET surface area extracted from the desorption isotherm was 72 m<sup>2</sup>/g and the total pore volume 0.27 cm<sup>3</sup>/g. The BJH pore size distribution is presented in Fig. 2b and shows a mean pore diameter of 13.6 nm.

#### 3.2 Modification of Zirconia with Ni(thd)<sub>2</sub> by ALD

The Ni(thd)<sub>2</sub> was evaporated at approximately 140 °C and led through a fixed bed of mesoporous zirconia stabilised at 200 °C. After the modification and cooling down, samples were taken from the top part of the fixed bed and mixing the rest of the material as one sample (see Fig. 1). According to the semiquantitative XRF measurements, the nickel content in the bed was on the order of 1 wt%, with the top sample containing more nickel than the mixed sample (this had ~60% of top-part content). For ALD, where saturation of the surface with adsorbed species has taken place throughout, a constant nickel concentration would be expected throughout the support bed. Full saturation had thus not taken place yet.

After the run, some Ni(thd)<sub>2</sub> was seen in the low-temperature condense tube at the reactor outlet. As the support bed had not saturated throughout, this means that at the flow conditions used in this work, some Ni(thd)<sub>2</sub> passed

the bed unreacted and the reactant usage was therefore not optimally efficient.

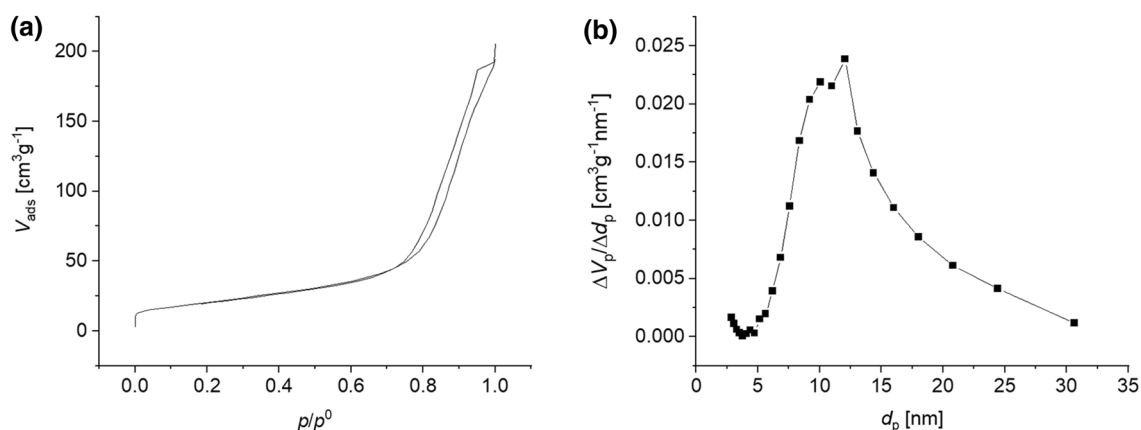
To compare with other catalyst ALD studies and also with ALD growth on planar materials, it is of interest to convert the nickel loading from wt% to atoms per unit surface area, typically nm<sup>2</sup> [3]. The nickel surface loading on zirconia with BET surface area of 72 m<sup>2</sup>/g was estimated to be on the order of 1 Ni/nm<sup>2</sup>.

For further characterization by XPS, SEM-EDS, TGA and DRIFT spectroscopy, a sample taken from the top part of the support bed was used.

#### 3.3 XPS

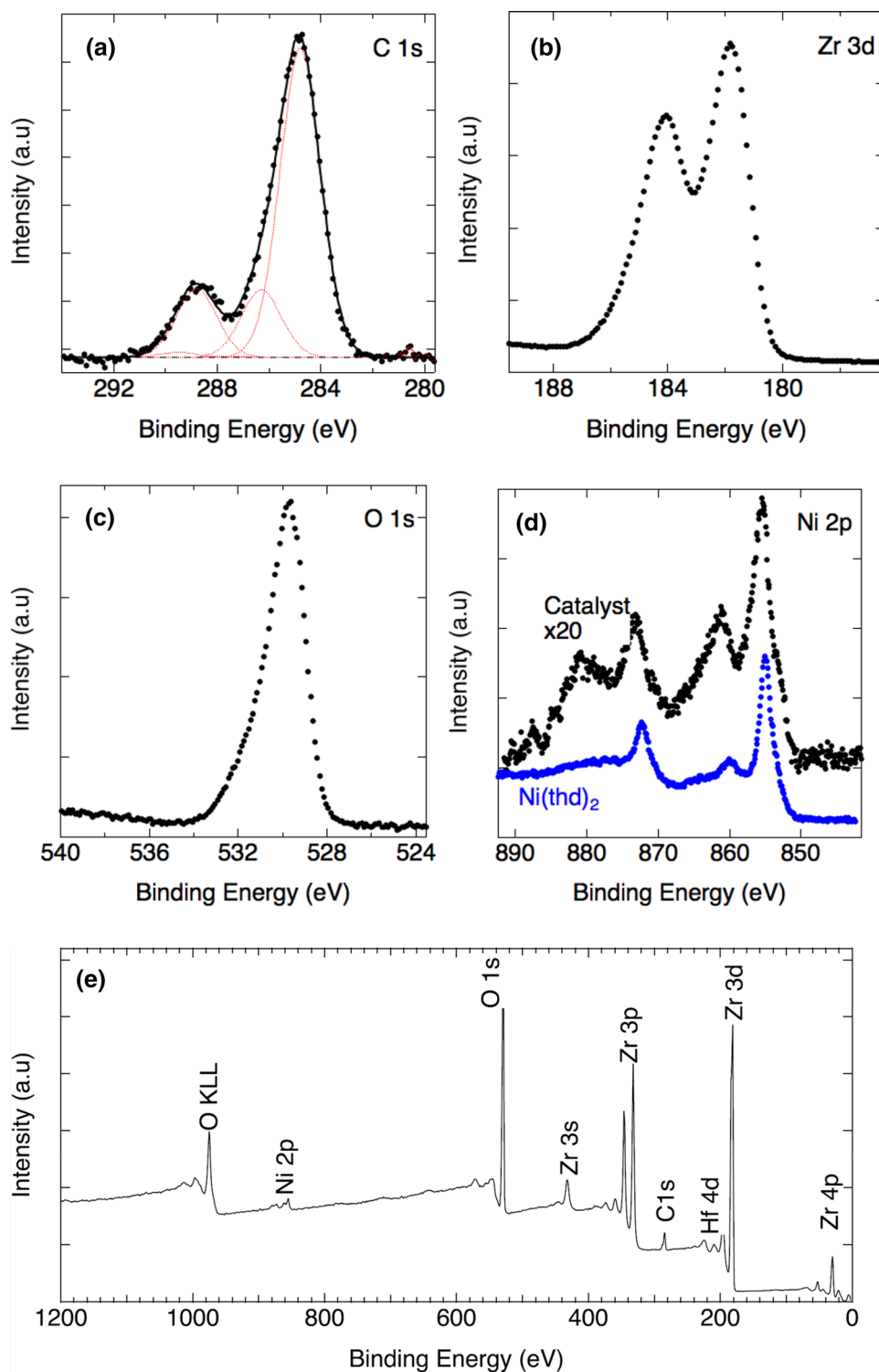
The wide spectrum and high resolution spectra of C 1s, Zr 3d, O 1s and Ni 2p regions are shown in Fig. 3. Based on the wide scan, the estimated Ni content of the surface layer was 2 at.%. For the high resolution spectra we performed a deconvolution of the C 1s spectrum (Fig. 3a) to estimate the binding energy (BE) of the main peak identified as adventitious carbon in order to get a good BE reference. After fitting, the most intense peak was shifted to 284.84 eV and all the other C-peaks as well as other spectra were corrected with the same offset. The other components visible in the C 1s spectrum correspond to different C–O-bonds normally visible after air exposure. The Zr 3p and O 1s spectra shown in Fig. 3 are typical for ZrO<sub>2</sub> with the Zr 3d5/2 peak close to 182 eV and the O 1s peak close to 530 eV.

The Ni 2p region shows the 2p3/2 peak at 855.5 eV and the 2p1/2 peak at 873.2 eV. Both peaks have a satellite roughly 6 eV above the main peak. We also measured pure Ni(thd)<sub>2</sub> for reference, and noticed that the shape of the spectrum is similar, although the intensities of the satellites compared to the main peak are higher in the Ni(thd)<sub>2</sub>-modified zirconia samples. The satellite intensity in the Ni(thd)<sub>2</sub> increased when the material was left in air for one



**Fig. 2** Results of nitrogen adsorption and desorption isotherms of the zirconia support: **a** volume of N<sub>2</sub> adsorbed  $V_{\text{ads}}$  (per gram of sample) as function of the relative pressure of nitrogen  $p/p^0$ , and **b** pore size ( $d_p$ ) distribution of the zirconia, as analysed with the BJH method

**Fig. 3** X-ray photoelectron spectra of Ni(thd)<sub>2</sub>-modified zirconia: **a** C 1s, **b** Zr 3d, **c** O 1s and **d** Ni 2p regions, and **e** the corresponding wide energy spectrum. **d** shows for comparison also the spectrum of Ni(thd)<sub>2</sub> reference



night (not shown). We expect this change is due to exposure to humidity. Deconvolution of the Ni spectrum was not performed, but we compared the Ni spectra against reference spectra of NiO and Ni(OH)<sub>2</sub> [58]. NiO reference shows two components in the 2p<sub>3/2</sub> peak around 855.5 eV separated by 1.7 eV not visible in our data. The Ni(OH)<sub>2</sub>

reference shows one main peak at 855.5 eV and a satellite 6 eV above that, resembling our data. However, the Ni(OH)<sub>2</sub> peaks reported by [58] are not sufficient to reproduce our data. This indicates slightly different environment for Ni atoms than in Ni(OH)<sub>2</sub> or NiO but their oxidation state seems to be two.



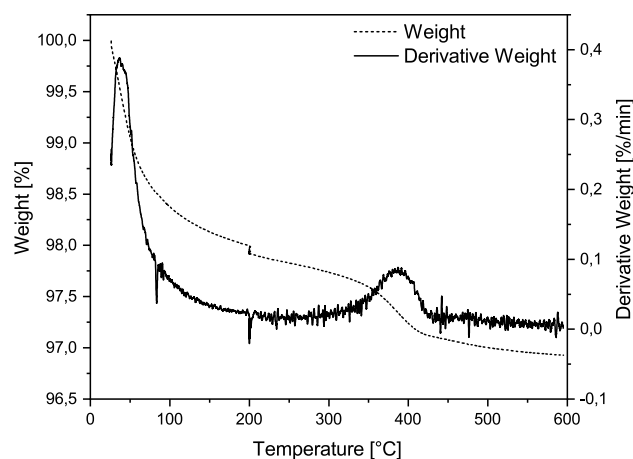
### 3.4 SEM-EDS

Initial EDS results showed the presence of Ni in the studied sample. The results concerning Ni distribution across a zirconia particle are presented in Fig. 4. Figure 4a illustrates the position of EDS line scan on top of backscattered electron image (BSE) of the zirconia particle. Figure 4b and c show measured X-ray intensities as a function of distance along the line scan. The Fig. 4b presents in principle both Zr and Ni intensities for L- and K-lines, respectively. Intensities coming from Ni are several orders of magnitude lower than intensities coming from Zr, however, and therefore not distinguishable in the figure. In Fig. 4c, the same results for Ni are presented using smaller intensity axis scaling. The measured X-ray intensities are proportional to the concentrations of Zr and Ni, respectively. Despite background noise, Ni was detected in zirconia particles in trace element amount. Furthermore, Ni was observed to be distributed throughout the zirconia particle.

### 3.5 TGA of Nickel-Modified Zirconia

After reacting  $\text{Ni}(\text{thd})_2$  with zirconia, at least one thd ligand was expected to remain on the surface. To increase the nickel loading by repeating ALD cycles, the remaining ligands needs to be removed. This can be done with air at an elevated temperature.

As a pre-test to find the suitable temperature for removal of the organic thd ligands, TGA analysis was made for the nickel-modified zirconia; the results are shown in Fig. 5. Significant weight loss likely due to dehydration and/or dehydroxylation was observed especially up to 200 °C, and to a small extent after that. An additional weight loss occurred at about 300–400 °C, which can likely be attributed to removal of the organic thd ligands by oxidation. Some weight loss continued after 400 °C.

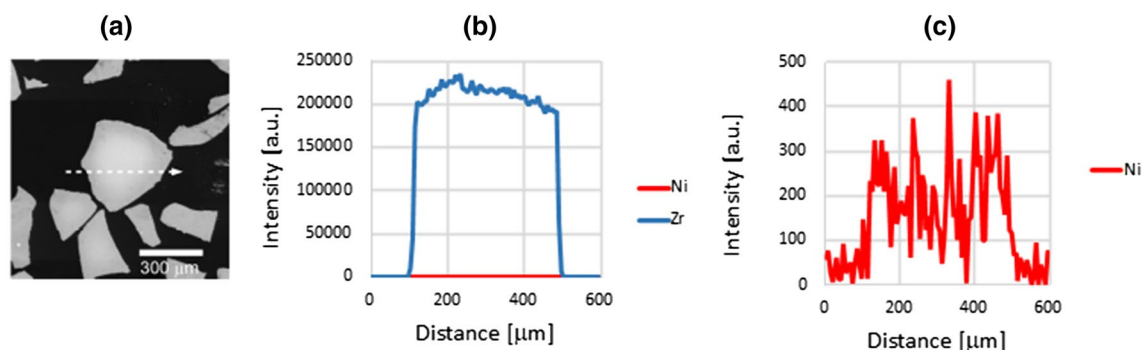


**Fig. 5** TGA curve of  $\text{Ni}(\text{thd})_2$ -modified  $\text{ZrO}_2$ , heated in  $\text{N}_2$  at 200 °C for 1 h to reduce moisture, continued by heating in  $\text{O}_2$  (200–600 °C) with a heating rate of 10 °C/h

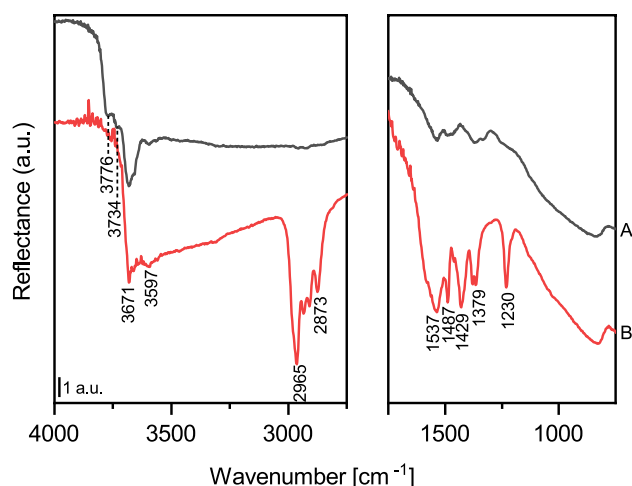
### 3.6 DRIFT Spectroscopy Observation of Thd Ligand Removal in Air

DRIFT spectroscopy was used to study how the thd ligands were attached to the zirconia support and for the removal of the thd ligands by oxygen during heating in air.

The zirconia support was measured as a reference and the spectrum at 30 °C was recorded after heating in  $\text{N}_2$  at 200 °C for 2 h (spectrum A in Fig. 6). The spectrum showed peaks at  $3776\text{ cm}^{-1}$  and  $3671\text{ cm}^{-1}$ , and a small shoulder between these two bands at  $3734\text{ cm}^{-1}$ . The peaks at  $3776\text{ cm}^{-1}$  and  $3671\text{ cm}^{-1}$  can be assigned to terminal and tribridged OH groups [59]. The small shoulder at  $3734\text{ cm}^{-1}$  is likely indicating the existence of bibridged OH groups [59]. Small bands observed between 1600 and  $1000\text{ cm}^{-1}$  can be assigned to residual carbonate groups trapped inside the zirconia bulk [60]. The spectrum of the zirconia support (spectrum A in Fig. 6) also showed moisture on the sample that was expected due to the pretreatment at low temperature



**Fig. 4** SEM-EDS results: **a** Backscattered electron image of zirconia particle showing the position of EDS line scan. **b** The EDS line scan of a zirconia particle. **c** The EDS line scan of a zirconia particle with smaller intensity axis scaling

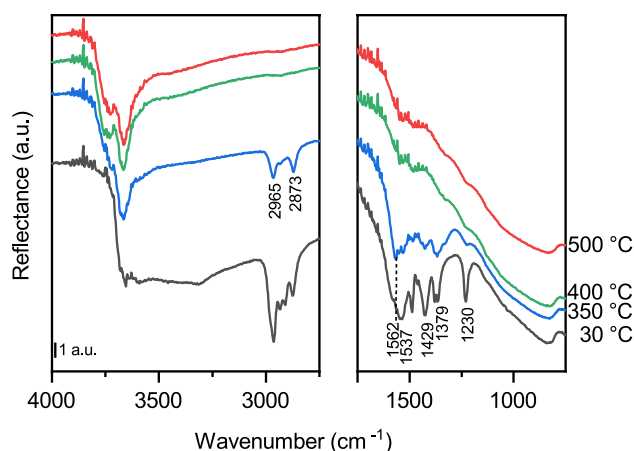


**Fig. 6** DRIFT spectra of **a**  $\text{ZrO}_2$  and **b**  $\text{Ni}(\text{thd})_2$ -modified zirconia at 30 °C after pre-heating at 200 °C for 2 h in  $\text{N}_2$ . Spectra shifted vertically for clarity

(200 °C). The OH groups have been reported to have more intense peaks when calcined at 600 °C for 2 h in air flow [59].

The spectrum of  $\text{Ni}(\text{thd})_2$ -modified zirconia (pretreated in  $\text{N}_2$  at 200 °C for 2 h and cooled down to 30 °C) showed several intense peaks (spectrum B in Fig. 6), indicating differences compared to the unmodified support (spectrum A in Fig. 6). The presence of adsorbed ligands on the nickel-modified zirconia is evidenced through the methyl group signals (C–H stretching and bending vibrations) at 2965–2873  $\text{cm}^{-1}$  and 1429–1230  $\text{cm}^{-1}$  [31, 61], as well as through bands related to the thd ligand at 1600–1488  $\text{cm}^{-1}$  (C=C and C=O stretching vibrations) [31]. Compared to the spectrum of the zirconia support (spectrum A in Fig. 6), it can be seen that the terminal and bibriged OH groups (at 3776 and 3734  $\text{cm}^{-1}$ ) have disappeared and the band for tribridged OH groups (at 3671  $\text{cm}^{-1}$ ) has decreased in the  $\text{Ni}(\text{thd})_2$  reaction. The absence of terminal hydroxyl groups suggests that  $\text{Ni}(\text{thd})_2$  consumed them during the reaction with zirconia; the same likely took place with the bibriged OH groups. Similarly, in earlier works, it has been reported that OH groups of zirconia, especially the terminal OH groups, react with the precursor in the ALD reaction of  $\text{Cr}(\text{acac})_3$  (acac = acetylacetonate) and zirconia support [62].

The DRIFT spectra measured during heating between 30 and 500 °C for the nickel-modified zirconia are shown in Fig. 7. The peaks assigned to the thd ligands stayed largely intact during heating in air up to 300 °C. At 350 °C, the C–H bands (at 2873–2965 and 1230–1429  $\text{cm}^{-1}$ ) and C–O bands (at 1488–1600  $\text{cm}^{-1}$ ) started to decrease in intensity and at 400 °C these bands disappeared. Thus, it can be concluded that thd ligands were completely decomposed via oxidation below 400 °C. These results are in line with those observed



**Fig. 7** DRIFT spectra of  $\text{Ni}(\text{thd})_2$ -modified zirconia, heated 30–500 °C in 10%  $\text{O}_2/\text{N}_2$ . Spectra have been collected with the sample at the indicated temperature (30–500 °C), after initially pre-heating at 200 °C for 2 h and cooling again to 30 °C in  $\text{N}_2$  (see Fig. 6). Spectra shifted vertically for clarity

earlier for  $\text{Ir}(\text{acac})_3$  and  $\text{Pt}(\text{acac})_2$  on alumina support, where acac ligands were oxidised below 500 °C [63].

To summarize, DRIFT spectroscopy results showed that the reaction of  $\text{Ni}(\text{thd})_2$  with the zirconia support brought out the expected thd ligands while consuming OH groups. These ligands can be decomposed and removed in the presence of oxygen by 400 °C, thus completing the first ALD cycle. The effective removal of ligands by heating in oxygen is essential for the future use of nickel-modified zirconia as a catalyst since unremoved ligands would affect the activity of a catalyst.

## 4 Conclusion

This article reports our first efforts to support nickel on mesoporous high-surface-area zirconia by ALD for catalytic purposes. A nickel loading of approximately 1 wt% was obtained by the  $\text{Ni}(\text{thd})_2$  reaction at 200 °C using a commercial fixed-bed powder ALD reactor. The corresponding surface loading on zirconia (with BET surface area of 72  $\text{m}^2/\text{g}$  and mean pore diameter of 14 nm) was on the order of 1 Ni/ $\text{nm}^2$ . Full saturation throughout the support bed was not yet attained in this initial work. According to XPS, all nickel had oxidation state two. According to SEM-EDS cross-sectional observation, at the top part of the fixed particle bed, nickel was observed throughout the zirconia particle. Organic thd ligands remained complete on the surface after the  $\text{Ni}(\text{thd})_2$  reaction with zirconia, as followed with DRIFT spectroscopy. The first ALD cycle was completed by oxidation, which removed the remaining organic ligands at approximately 400 °C and re-created OH groups on the surface.



To use the Ni/zirconia materials as catalysts, it is advisable to ensure full saturation throughout the support bed and within the zirconia particles. Further optimization work is needed to ensure saturation and increase the nickel loading before catalytic testing.

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